

Attorney Docket No. 10113391

OCT 12 2005

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kaan-Lu TZOU, Tzu-Ching TSAI,
Yi-Nan CHEN

Filed: 12/4/2003

Appl. No.: 10/727,790

Examiner: IVEY, ELIZABETH D

Conf. No.: 6818

Art Unit: 1775

Title: MULTI-LAYER HARD MASK STRUCTURE FOR ETCHING DEEP TRENCH
IN SUBSTRATE

Date: October 12, 2005

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT COVER SHEET

Sir:

Attached hereto please find an Amendment in response to the Office Action mailed on
July 12, 2005.

No fee is believed to be due in connection with this Amendment. If, however, the
Commissioner considers that a fee is due in connection with this Amendment,
authorization is made to charge any fee which may be required to Deposit Account No.
502447. In particular, if this response is not timely filed, then the Commissioner is
authorized to treat this response as including a petition to extend the time period
pursuant to 37 C.F.R. § 1.136(a) requesting an extension of time of the number of
months necessary to make this response timely filed and the petition fee due in
connection therewith may be charged to Deposit Account No. 502447.

P113406NAQ

Page 1 of 2

Attorney Docket No. 10113391

PATENT**Certificate of Mailing or Transmission**

I hereby certify that this correspondence is being deposited with the United States Postal service with sufficient postage as first class mail in an envelope addressed to Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, or is being facsimile transmitted to the United States Patent & Trademark Office to (571) 273-8300 on the date shown below:

Nelson A. Quintero

(Name of Person Transmitting)

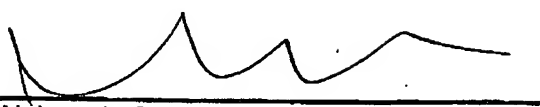


(Signature)

October 12, 2005

(Date)

Respectfully submitted,



Nelson A. Quintero

Attorney for Applicant

Reg. No. 52,143

Customer No. 34,283

Telephone: (310) 401-6180

Attorney Docket No. 10113391

OCT 12 2005

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kaan-Lu TZOU, Tzu-Ching TSAI,
Yi-Nan CHEN

Filed: 12/4/2003

Appl. No.: 10/727,790

Examiner: IVEY, ELIZABETH D

Conf. No.: 6818

Art Unit: 1775

Title: MULTI-LAYER HARD MASK STRUCTURE FOR ETCHING DEEP TRENCH
IN SUBSTRATE

Date: October 12, 2005

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

The Office Action mailed on July 12, 2005 has been carefully considered. In response thereto, the Applicant respectfully requests entry of the amendments and consideration of the remarks as set forth herein below:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.

All amendments and remarks made herein are without prejudice.